

CÓDIGO SERVICIO: 824881

SALA BLANCA de MICRO y NANOFABRICACIÓN
MICRO AND NANOFABRICATION CLEAN ROOM

2026 Rates					
CONCEPT	CUSTOMER				
	ICMM	CSIC	UAM Excellence Campus and CSIC Joint Centers (CIF no CSIC)	Spanish public Universities, AGE, OPIS	Private Organizations/ Others
Photolithography: pattern fabrication (€/sample)	21.57	25.30	25.30	66.24	72.54
Maskless UV photolithography (€/sample)	22.53	26.43	26.43	67.23	73.63
Two-photon 3D lithography – Nanoscribe (€/sample)	24.28	28.49	28.49	69.76	76.40
Metallization (Sputtering): General (€/hour)	5.46	6.41	6.41	45.35	49.67
Samples treatment: metallization by evaporation: General (€/hour)	10.53	12.36	12.36	52.42	57.42
Physical Vapour Deposition: ALD (atomic layer deposition) (€/hour)	6.74	7.90	7.90	47.00	51.48
Packaging-Assembly: Wire bonding ball (€/hour)	1.58	1.85	1.85	40.32	44.16
Plasma treatment of surfaces (€/process)	4.26	5.00	5.00	43.80	47.97
Four-point probe electrical characterization (€/hour)	1.87	2.19	2.19	40.69	44.56

NOTE: Rates do not include VAT if applicable.